

## Set-up for electrical, photoelectrical, Hall effect and magnetoresistance characterizations of semiconductor nanostructured materials

Accurate measurements are performed:

- (photo)current – voltage characteristics at different temperatures (10-500K);
- current – temperature characteristics at different voltages ( -1000 ÷ +1000V);
- spectral dependence of photocurrent;
- capacitance – voltage characteristics;
- Hall measurements at different magnetic fields and temperatures (4 – 300K);
- current–voltage characteristics at different magnetic fields and temperatures (4–300K);



**(1) Set-up for electrical transport and photoelectrical measurements:** cryostat (10K – 500K); electrometer 6517A (1fA - 20mA; 10  $\mu$ V – 200 V; 50  $\Omega$  – 1  $0^{16}$   $\Omega$ ); source 0V  $\pm$  1000V); Keithley 2000 multimeter; monochromator, (250 nm–3000 nm); light source (450 – 1000 W); chopper SR 540 (6-4000 Hz); duple lock-in SR 830 (1mHz – 102,4 kHz; sensibilitate 2nV – 1 V); Keithley 8009 resistivity test fixture; Temperature controller 331; Vacuum equipment ( $10^{-6}$  torr); RLC (2Hz – 20MHz; 40V); LabView 8.5

**(2) Set-up for Hall effect and magnetoresistance measurements:** Janis magnetic criostat (4K – 300K); LakeShore electromagnet EM4-HVA (2,5 T) with power supply 642 (0 -70A) and temperature controller 331S; Chiller (2200 W, 5 – 40  $^{\circ}$ C); source E3631A (0  $\pm$  25 V, 5 A); multimeter 34401A; Vacuum equipment ( $10^{-6}$  torr).